

Photonic metamaterials by direct laser writing and silver chemical vapour deposition

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Metamaterials are artificial materials that—unlike natural substances—enable magnetism to be achieved at optical frequencies^{1–3}. The vast majority of photonic metamaterials^{4,5} has been fabricated by electron-beam lithography and evaporation of metal films, both of which are well-established two-dimensional (2D) technologies. Although stacking of three⁶ or four⁷ functional layers made using these methods has been reported, a truly 3D fabrication approach would be preferable for 3D photonic metamaterials. Here, we report first steps in this direction by using a combination of direct laser writing^{8,9} and silver chemical vapour deposition^{10,11}—the 3D analogues of electron-beam lithography and evaporation, respectively. The optical characterization of a planar test structure composed of elongated split-ring resonators is in good agreement with theory. Retrieval of the effective optical parameters reveals the importance of bi-anisotropy. Once suitable theoretical blueprints are available, our fabrication approach will enable rapid prototyping of truly 3D photonic metamaterials.

The emerging field of photonic metamaterials is driven by the fascinating visions of perfect lenses¹², optical cloaking^{13,14} or quantum levitation¹⁵. Realizing these visions clearly ultimately requires large-scale three-dimensional (3D) metamaterials operating at optical frequencies. One of the major challenges concerns the (realistic) design and the nanofabrication of such structures. The latter is related to the fabrication of 3D (dielectric) photonic crystals, for which extensive literature is available (see, for example, the references in a recent review¹⁶). It has become clear that polymeric templates made using holography and/or direct laser writing (DLW) can subsequently be converted into, for example, silicon structures using chemical vapour deposition (CVD) and/or atomic-layer deposition (ALD). In the context of metamaterials, however, metals are crucial; silver leads to the lowest losses at optical frequencies¹⁷. Yet, it has been unclear whether structures made using DLW and silver CVD would ever have sufficient quality and whether achievable feature sizes would result in metamaterials operating at optical frequencies. Fortunately, we report here that the answer is positive in both regards. Combined with suitable theoretical blueprints, which still need to be developed, this result means that one of the major hurdles in the field of photonic metamaterials is starting to disappear.

Lithography of 3D polymeric templates by DLW with lateral feature sizes in the 100 nm range has become routine^{8,9,18} and is even available commercially¹⁹. Our vision is to take such a template and coat it with a silver film of a few tens of nanometres in thickness, for example leading to the 3D arrangement of magnetic split-ring resonators (SRR) shown in Fig. 1a. Several questions arise immediately. (1) Silver films made using these methods are obviously always inherently connected—in sharp contrast to those made by electron-beam lithography. Can meaningful properties, especially a magnetic response, still be achieved? (2) The quality of silver films made using CVD is usually nowhere close to that of films made using high-vacuum evaporation. ALD of silver has never been reported. Can a high-quality metamaterial optical response still be accomplished? To address these questions, we consider the much simpler arrangement of SRRs shown in Fig. 1b. It can be viewed as a 1D lattice of elongated SRRs or simply as a corrugated surface^{20–22}.

The fabrication starts with a glass substrate covered with a 2- μm -thick fully polymerized resist film (SU-8). Another SU-8 film is spun-on, exposed using DLW, post-baked and developed. The resulting SU-8 template is coated with a thin layer of SiO₂ (typically a few tens of nanometres) using ALD with SiCl₄ as the precursor²³. The SiO₂ surface is subsequently exposed to O₂ plasma for 15 min to activate the surface. The SiO₂ layer provides mechanical stability as well as chemical protection for the SU-8 backbone in the following silver CVD process in which the template needs to be heated to 160 °C. Here, the metal–organic precursor (COD)(hfac)Ag(I) is sublimed at a temperature of 60 °C; the wall temperature of the CVD chamber is 80 °C. In each static cycle of 40 min in duration, we deposit about 5 nm of silver. The samples discussed below have resulted from 10 CVD cycles, equivalent to an estimated silver thickness of about 50 nm. Figure 2 shows electron micrographs of structures made using these methods. Importantly, the structure shown in Fig. 2b demonstrates that the coating is uniform around the structure even in 3D—in sharp contrast to a usual 2D evaporation process. The films are somewhat granular but they are connected. This crucial aspect is demonstrated by the fact that the silver films exhibit good d.c. conductivity, by a reflectance $R > 95\%$ in the 1–4 μm wavelength range, and by the optical properties to be discussed next.

To determine the optical properties of the metamaterial layer, we have measured normal-incidence transmittance spectra using a

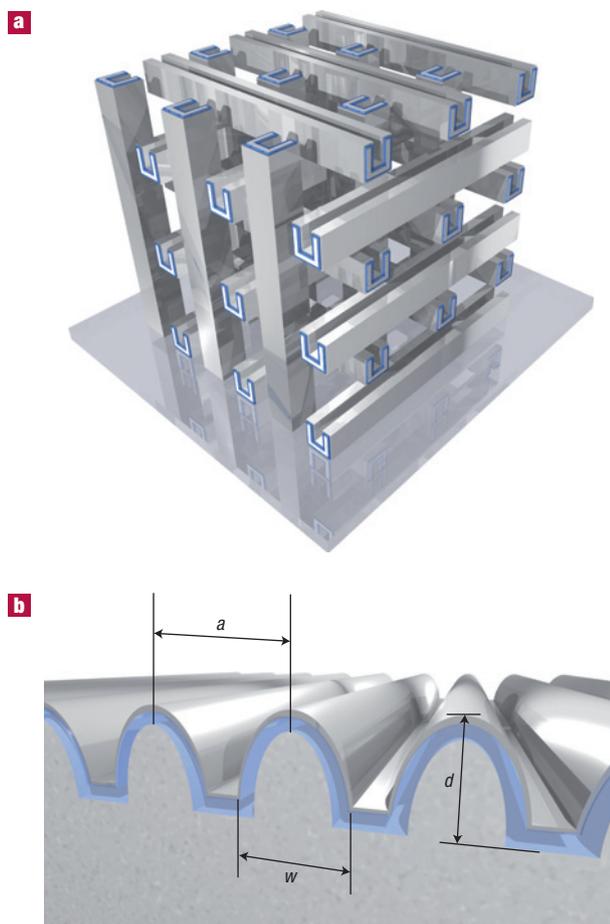


Figure 1 Metamaterial structures. **a**, A hypothetical 3D arrangement of elongated SRRs. Owing to the anticipated DLW and silver CVD fabrication process, all metal parts are connected. **b**, A planar lattice of elongated SRRs, again all connected. The latter structure shall serve as a reasonably simple test bed for the novel fabrication approach outlined here. Polymer (light grey), silica (blue) and silver (dark grey, reflective).

Fourier-transform microscope spectrometer (Bruker Equinox 55, near-infrared halogen source and Bruker Hyperion 2000, $\times 36$ Cassegrain objectives, numerical aperture: 0.5, liquid-N₂-cooled InSb detector). Results for the incident light being polarized vertically to the grooves of the elongated SRRs are shown in Fig. 3a. Different heights d correspond to different fundamental resonance frequencies. Intuitively, reducing the height leads to a reduction of the SRR cross-section and thus of its inductance L (C is its capacitance), and hence to an increase of the SRR LC eigenfrequency (decrease of the wavelength λ) at fixed lattice constant $a = 800$ nm. Notably, the structure with $d = 740$ nm (blue curve) reveals a ratio of about $\lambda/a = 4$, which is well separated from the Rayleigh anomalies and the Bragg condition, that is, the effective-medium approximation is well justified.

To enable a direct comparison with the theoretical ideal, we have carried out 3D finite-difference time-domain calculations using the software package CST Microwave Studio. The refractive indices of dielectrics used are $n_{\text{SU-8}} = 1.55$ and $n_{\text{SiO}_2} = 1.50$. Here, the silver film thickness, t_{Ag} , has been used as an adjustable parameter, leading to $t_{\text{Ag}} = 30$ nm. As usual, the silver optical properties are described by the free-electron Drude model with literature parameters⁶, that is, plasma frequency

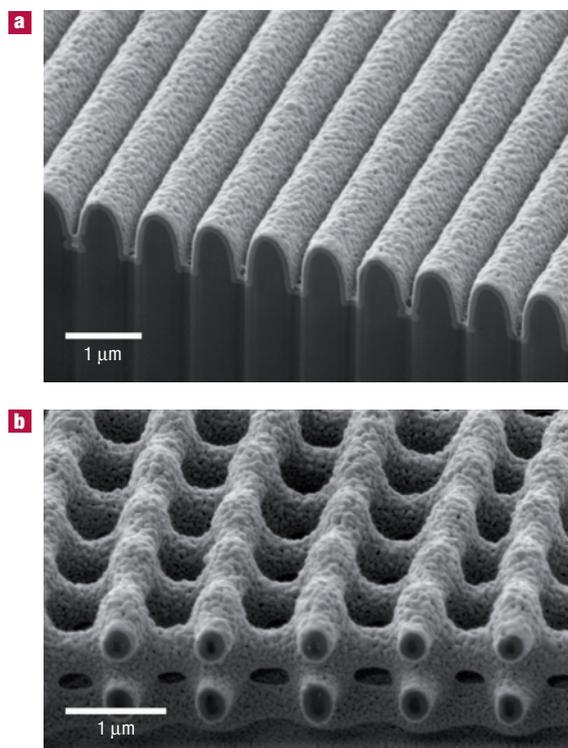


Figure 2 Electron micrographs of fabricated structures. The oblique views show structures that have been cut by a focused-ion beam after fabrication to reveal the interior (rather than an edge). **a**, Metamaterial corresponding to the design schematically shown in Fig. 1b. The focused-ion-beam cut reveals the SiO₂ layer between the SU-8 template and the silver coating. **b**, A 3D structure composed of bars. Note that the silver coating covers the bars all around.

$\omega_{\text{pl}} = 1.37 \times 10^{16} \text{ s}^{-1}$ and collision frequency $\omega_{\text{col}} = 8.50 \times 10^{13} \text{ s}^{-1}$. Figure 3b shows numerically calculated transmittance spectra corresponding to the experiment and plotted on the same horizontal and vertical scales. The overall agreement is good, especially regarding the position of the magnetic resonance, the depth of this resonance and the general qualitative trends with SRR height d . Quantitative deviations can partly be due to systematic variations in the thickness of the silver film. Furthermore, the statistical roughness of the metal film can lead to Rayleigh scattering. This effect tends to decrease the transmittance on the short-wavelength side of the spectrum, especially for effectively thicker structures (larger d). Finally, it should be noted that the Cassegrain optics in the experiment collects opening angles between 15° and 30° around the surface normal, whereas the calculations refer to strictly normal incidence. Our finite-difference time-domain approach does not allow calculations for oblique incidence. However, we have also carried out extra calculations based on a scattering-matrix approach, for oblique incidence of light, but for a simplified rectangular SRR shape. Here, we find changes in the transmittance spectra for angles between 0° and 30° that are comparable to the mentioned deviations between experiment and theory in Fig. 3a and b, respectively.

Altogether, we have sufficient confidence in the theory to extract the effective optical parameters on the basis of these calculations. Extreme caution has to be taken at this point. The metamaterial structure (Fig. 1b or Fig. 2a) clearly lacks inversion symmetry along the propagation direction. Thus, a parameter retrieval²⁴ in terms of complex permittivity ϵ and complex permeability μ

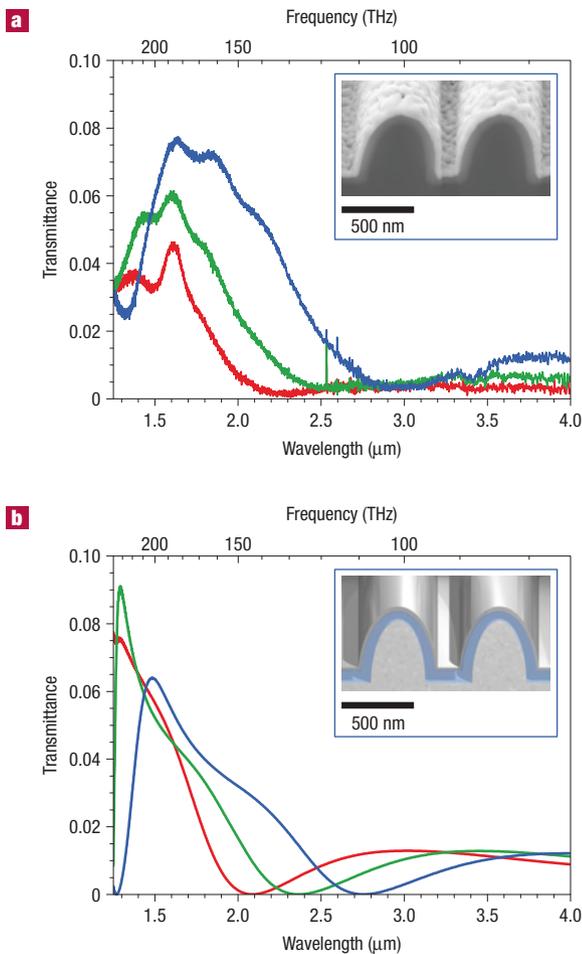


Figure 3 Normal-incidence optical transmittance spectra. **a**, Experiment. **b**, Corresponding theory. The incident linear polarization is perpendicular to the grooves shown in Figs 1b and 2a. The insets show an electron micrograph of a corresponding structure (blue curve) and an illustration of the geometry used in the calculations, respectively. Mainly, the height d of the structure (Fig. 1b) has been varied: $d = 580$ nm (red curve), $d = 640$ nm (green curve) and $d = 740$ nm (blue curve). Owing to the fabrication process, the width w also changes: $w = 590$ nm and $w = 500$ nm, respectively.

alone is generally not possible as this always leads to a symmetric reflectance, whereas the actual reflectance is not symmetric, that is, it depends on which side it is taken from. The general underlying physics of bi-anisotropy has been discussed in the literature^{25,26} (alternatively, the behaviour can be expressed in terms of a non-local response²⁷). Here, we are not interested in the general tensor formulation²⁵ and can restrict ourselves to the 1D situation. If the incident light is polarized vertically to the grooves of the elongated SRRs, the relation between the relevant vector components of the electromagnetic fields in the Maxwell equations can be simplified to

$$\begin{pmatrix} D \\ B \end{pmatrix} = \begin{pmatrix} \varepsilon_0 \varepsilon & -i c_0^{-1} \xi \\ +i c_0^{-1} \xi & \mu_0 \mu \end{pmatrix} \begin{pmatrix} E \\ H \end{pmatrix}.$$

The complex refractive index n results from $n^2 = \varepsilon \mu - \xi^2$. ε_0 is the vacuum permittivity, μ_0 is the vacuum permeability and c_0 is the vacuum speed of light. As usual, the permittivity ε describes excitation of electric dipoles by the electric component of the incident electromagnetic field, and μ describes the excitation of magnetic dipoles by the magnetic component. The bi-anisotropy

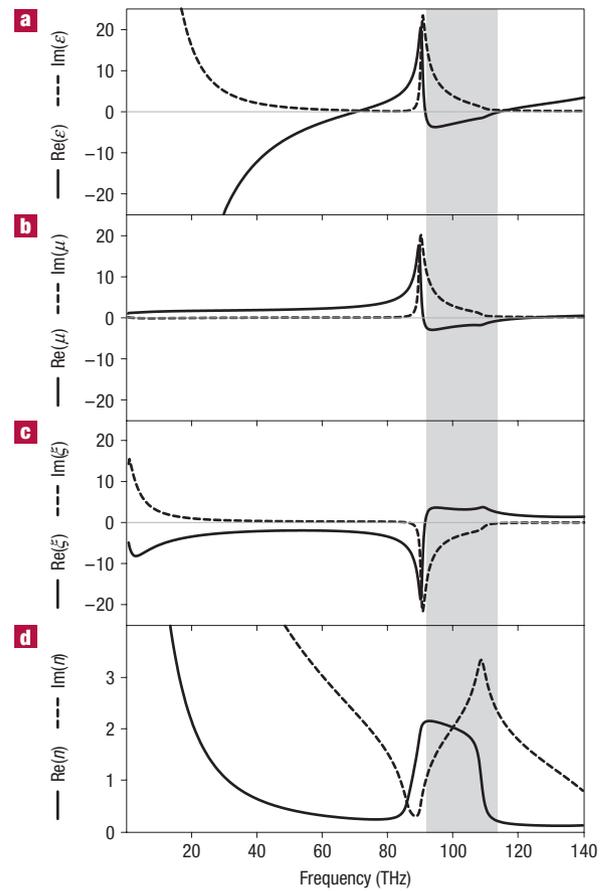


Figure 4 Retrieved effective metamaterial parameters. Real and imaginary parts of the complex parameters. **a**, Electric permittivity ε . **b**, Magnetic permeability μ . **c**, Bi-anisotropy parameter ξ . **d**, Refractive index n . Note the magnetic resonance at a frequency of around 100 THz ($3 \mu\text{m}$ wavelength) and that $\text{Re}(\mu) > 0$, whereas $\text{Re}(\varepsilon) < 0$ and $\text{Re}(\mu) < 0$ owing to the substantial influence of ξ . Parameters correspond to Fig. 3b, $d = 740$ nm (blue curve).

parameter ξ (see off-diagonal terms in the matrix) describes the excitation of magnetic dipoles by the electric component of the field and vice versa. Reciprocity demands that the two off-diagonal terms are identical up to the minus sign.

Resulting retrievals (see the Methods section) are shown in Fig. 4. The magnetic permeability μ does exhibit the anticipated magnetic resonance with $\text{Re}(\mu) < 0$ in a certain frequency interval, showing that our primary goal of fabricating a magnetic metamaterial using DLW and silver CVD has been accomplished. At first sight, ignoring the effects of bi-anisotropy, it might be tempting to conclude that the real part of the refractive index should be negative from the fact that the condition $\text{Re}(\varepsilon) < 0$ holds in an overlapping frequency interval. Yet, the influence of bi-anisotropy is far from being a detail or a correction and rather gives a positive resonance in $\text{Re}(n) > 0$.

Metamaterial losses can be quantified by the ratio of the real and imaginary parts of the refractive index, $\text{Re}(n)/\text{Im}(n)$ (Fig. 4d). This ratio reaches a maximum of about five. Thus, the very low transmittance of the structure shown in Fig. 3a,b is not a result of losses, but rather a result of the large impedance mismatch between the metamaterial and vacuum or glass substrate, respectively.

In summary, we have shown that high-quality magnetic metamaterials at near-infrared frequencies can be fabricated using

the combination of direct laser writing of polymer templates and silver chemical vapour deposition—the 3D analogues of 2D electron-beam lithography and 2D evaporation. Our approach enables rapid prototyping of complex 3D photonic metamaterials. Currently, however, we are facing a bottleneck in that theory has not yet provided blueprints for 3D metamaterials compatible with this approach. We hope that such theoretical progress will be stimulated by our work, as it is becoming increasingly clear that truly 3D photonic metamaterials of the future will very likely not just be miniaturized versions of their microwave counterparts²⁸.

METHODS

The Fresnel equations of a bi-anisotropic material for normal incidence enable calculation of the complex transmittance coefficients t_{air} and t_{sub} (incident light propagates at first through the substrate) as well as the two complex reflectance coefficients r_{air} and r_{sub} (light is reflected at the substrate–structure interface). Inversion of these equations leads to the relative impedances $z_{\pm} = (-b \mp \sqrt{b^2 - 4ac}) / (2a)$, with

$$a = t_{\text{air}}t_{\text{sub}} - (1 - r_{\text{air}})(1 - r_{\text{sub}}),$$

$$b = (z_{\text{air}} - z_{\text{sub}})(t_{\text{air}}t_{\text{sub}} + 1 - r_{\text{air}}r_{\text{sub}}) + (z_{\text{air}} + z_{\text{sub}})(r_{\text{air}} - r_{\text{sub}}),$$

$$c = z_{\text{air}}z_{\text{sub}}(-t_{\text{air}}t_{\text{sub}} + (1 + r_{\text{air}})(1 + r_{\text{sub}})),$$

and the refractive index n from

$$\cos(nk_0d) = \frac{t_{\text{air}}}{2} \left[\frac{\left(1 - \frac{z_{-}}{z_{\text{sub}}}\right)}{\left(1 - \frac{z_{-}}{z_{\text{air}}}\right) + r_{\text{air}}\left(1 + \frac{z_{-}}{z_{\text{air}}}\right)} + \frac{\left(1 - \frac{z_{+}}{z_{\text{sub}}}\right)}{\left(1 - \frac{z_{+}}{z_{\text{air}}}\right) + r_{\text{air}}\left(1 + \frac{z_{+}}{z_{\text{air}}}\right)} \right]. \tag{1}$$

k_0 is the vacuum wavenumber, d is the thickness of the effective medium, $z_{\text{sub}} = Z_{\text{sub}}/Z_0$ is the relative substrate impedance and $z_{\text{air}} = Z_{\text{air}}/Z_0 = 1$ is the relative vacuum impedance with the absolute vacuum impedance $Z_0 = \sqrt{\mu_0/\epsilon_0}$. Clearly, the inverse of equation (1) has different roots owing to the inverse cosine. Regarding selecting the correct root, we proceed as in the symmetric case²⁴. Finally, for the material parameters, we derive $\xi = in(z_{-} + z_{+}) / (z_{-} - z_{+})$, $\mu = z_{+}(n - i\xi)$ and $\epsilon = (n + i\xi) / z_{+}$.

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